EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S5	140675	(dop$6 or ionimplant $6 or bombard$6 or implant$6) near20 (B or As or P or Sb or In) near20 (semiconductor or substrate or wafer)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/08 15:57
S6	2491	S5 and (plasma near10 (inactive or inert or (rare adj gas) or He or helium))	US-PGPUB; USPAT	OR	ON	2009/04/08 15:59
S7	291	S6 and (plasma near20 (inactive or inert or (rare adj gas) or He or helium) near20 (expos$6 or irradiat$6 or treat$6) near20 surface)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/08 16:02

7/31/09 4:55:21 PM
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